

ABSTRACT

~~The subject of the invention is a~~ A transparent substrate, especially made of comprises glass[[,]] and is provided with a thin-film stack comprising including a plurality of functional layers, ~~characterized in that said~~ layers. ~~The~~ thin-film stack comprises at least three silver-based functional layers, ~~in that said~~ layers. ~~The thin-film~~ stack has a resistance $R_{\square} < 1.5 \Omega$ per square, ~~and in that said~~ The transparent substrate may undergo at least one transformation operation involving a heat treatment at a temperature of at least 500°C, so as to make it possible to achieve, using the substrate, alternatively or cumulatively, thermal control and/or electromagnetic shielding and/or heating.

~~Figure for the abstract: No figure~~